

# UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/802,811	03/18/2004	Tetsuji Sato	250645US2	5882
22850 7590 11/30/2007 OBLON, SPIVAK, MCCLELLAND MAIER & NEUSTADT, P.C. 1940 DUKE STREET			EXAMINER	
			ALEJANDRO MULERO, LUZ L	
ALEXANDRIA, VA 22314			ART UNIT	PAPER NUMBER
			1792	
	•			
		·	NOTIFICATION DATE	DELIVERY MODE
			11/30/2007	ELECTRONIC

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

patentdocket@oblon.com oblonpat@oblon.com jgardner@oblon.com

	Application No.	A1:4(-)			
	Application No.	Applicant(s)			
Office Acide a Communication	10/802,811	SATO, TETSUJI			
Office Action Summary	Examiner	Art Unit			
	Luz L. Alejandro	1792			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE!	I.  nely filed  the mailing date of this communication.  D (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 09/1	<u>3/07</u> .				
2a)⊠ This action is <b>FINAL</b> . 2b)□ This	This action is FINAL. 2b) ☐ This action is non-final.				
3) Since this application is in condition for allowa	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is				
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims	,	•			
4) ☐ Claim(s) 1-7 and 9-15 is/are pending in the ap 4a) Of the above claim(s) is/are withdra 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-7 and 9-15 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	wn from consideration.				
Application Papers					
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomposed and all accomposed and all accomposed and accomposed accomposed and accomposed and accomposed accomposed and accomposed accompo	cepted or b) objected to by the liderawing(s) be held in abeyance. See tion is required if the drawing(s) is objected.	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>					
Attachment(s)	•				
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ate			

10/802,811 Art Unit: 1792

#### **DETAILED ACTION**

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claim 9 is rejected under 35 U.S.C. 102(b) as being anticipated by Taniguchi et al., US 5,266,119.

Taniguchi et al. shows the invention as claimed including a vacuum processing apparatus comprising: a vacuum chamber 56d accommodating therein a substrate 1 to be processed, allowing an inner space of the vacuum chamber to be maintained at a vacuum level; a first structure 55 fixedly disposed at a location in the vacuum chamber; a second structure 50 installed in the vacuum chamber and facing the first structure, the second structure being vertically movable so as to vary a distance between the first structure and the second structure; a driving mechanism for vertically moving the second structure, the driving mechanism being installed outside the vacuum chamber; a bellows unit 8d/8e/8f for airtightly sealing an opening, the bellows unit having an upper bellows portion 8d/8e, a lower bellows portion 8f, and a ring member 8c connected to the driving mechanism, wherein the opening, through which the second structure is driven by the driving mechanism via the ring member, is provided at the vacuum chamber, and the ring member is disposed between the upper bellows portion and the lower bellows portion; and a structure supporting member 7 for supporting the second

Art Unit: 1792

structure connecting the ring member to the second structure, the structure supporting member being installed in the vacuum chamber, wherein the upper bellows portion and the lower bellows portion are oppositely extended and contracted in accordance with a vertical movement of the ring member while maintaining a constant total length of the bellows unit (see, the entire document, especially fig. 2 and col. 5-line 64 to col. 9-line 44).

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-7 and 9-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tomoyoshi et al., US 2004/0035364 in view of Taniguchi et al., US 5,266,119.

Tomoyoshi et al. shows the invention substantially as claimed including a plasma processing apparatus comprising: a vacuum chamber 1/11 accommodating therein a substrate to be processed, allowing an inner space of the vacuum chamber to be maintained at a vacuum level; a first electrode 3/13 capable of being fixedly disposed at a location in the vacuum chamber; a second electrode 2/12 installed in the vacuum chamber and facing the first electrode, the second electrode being vertically movable so as to vary a distance between the first electrode and the second electrode; a driving

10/802,811 Art Unit: 1792

mechanism for vertically moving the second electrode, the driving mechanism being installed outside the vacuum chamber; a bellows unit 7/17 for airtightly sealing an opening; and a high frequency power source 14/15 generating plasma between the first electrode and the second electrode (see, for example, figs. 1 and 6 and their descriptions).

Tomoyoshi et al. does not expressly disclose the claimed upper bellows/lower bellows/ring/supporting member structure. Taniguchi et al. discloses an apparatus including a bellows unit having an upper bellows portion 8d/8e, a lower bellows portion 8f, and a ring member 8c connected to a driving mechanism, wherein the opening, through which the second structure is driven by the driving mechanism via the ring member, is provided at the vacuum chamber, and the ring member is disposed between the upper bellows portion and the lower bellows portion, and a structure supporting member 7 for connecting the ring member to the second structure, the structure supporting member being installed in the vacuum chamber, wherein the upper bellows portion and the lower bellows portion are oppositely extended and contracted in accordance with a vertical movement of the ring member while maintaining a constant total length of the bellows unit (see the entire document, especially the Summary of the Invention and fig. 2 and its description). Therefore, in view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Tomoyoshi et al. so as to comprise the claimed upper bellows/lower bellows/ring/ supporting member structure in order to provide a small-

10/802,811 Art Unit: 1792

sized and inexpensive sealing mechanism for the processing apparatus that can reduce or remove the thrust/force applied to the substrate/electrode support moving structure.

With respect to claims 2 and 10, it would have been an obvious choice of design to one having an ordinary skill in the art at the time the invention was made to modify the apparatus of Tomoyoshi et al. modified by Taniguchi et al. as to have the lower electrode as the first fixed electrode and the upper electrode as the second movable electrode if movement of the upper electrode instead of the lower electrode is desired, and such limitation would not lend patentability to the instant application absent the showing of unexpected results.

Concerning claims 3-7 and 11-15, note that the upper electrode 3/13 of the apparatus of Tomoyoshi et al. is supported from underneath the lower electrode (by structures 1/11 and 9/19); the electrode supporting member includes an exhaust ring 8/18 for uniformly exhausting the vacuum chamber and a cylindrical member 9/19-20 for protecting an inner wall of the vacuum chamber.

Concerning claims 6-7 and 14-15, note that the apparatus of Tomoyoshi et al. in view of Taniguichi et al. further comprises a substrate supporting member for supporting the substrate to be processed above the lower electrode, wherein the substrate supporting member is vertically movable by the driving mechanism to pass through the lower electrode. With respect to claims 7 and 15, note that the distance between the first electrode and the second electrode in the apparatus of Tomoyoshi et al. modified by Taniguchi et al. is varied while constantly maintaining a volume of the vacuum chamber maintained in vacuum.

10/802,811 Art Unit: 1792

Claims 1-2 and 9-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Koshimizu, US 5,980,687 in view of Taniguchi et al., US 5,266,119.

Koshimizu shows the invention substantially as claimed including a plasma processing apparatus comprising: a vacuum chamber 102 accommodating therein a substrate W to be processed, allowing an inner space of the vacuum chamber to be maintained at a vacuum level; a first lower electrode 110 capable of being fixedly disposed at a location in the vacuum chamber; a second upper electrode 116 installed in the vacuum chamber and facing the first electrode, the second electrode being vertically movable so as to vary a distance between the first electrode and the second electrode; a driving mechanism 120 for vertically moving the second electrode, the driving mechanism being installed outside the vacuum chamber; a bellows unit 122 for airtightly sealing an opening; and a high frequency power source 130/134 generating plasma between the first electrode and the second electrode (see figs. 1 and 3 and their descriptions).

Koshimizu does not expressly disclose the claimed upper bellows/lower bellows/ring/supporting member structure. Taniguchi et al. discloses an apparatus including a bellows unit having an upper bellows portion 8d/8e, a lower bellows portion 8f, and a ring member 8c connected to a driving mechanism, wherein the opening, through which the second structure is driven by the driving mechanism via the ring member, is provided at the vacuum chamber, and the ring member is disposed between the upper bellows portion and the lower bellows portion, and a structure supporting

10/802,811 Art Unit: 1792

member 7 for supporting the second structure and connecting the ring member to the second structure, the structure supporting member being installed in the vacuum chamber, wherein the upper bellows portion and the lower bellows portion are oppositely extended and contracted in accordance with a vertical movement of the ring member while maintaining a constant total length of the bellows unit (see the entire document, especially the Summary of the Invention and fig. 2 and its description).

Therefore, in view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Koshimizu so as to comprise the claimed upper bellows/lower bellows/ring/ supporting member structure in order to provide a small-sized and inexpensive sealing mechanism for the

processing apparatus that can reduce or remove the thrust applied to the carrier shaft.

Claims 3-7 and 11-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Koshimizu, US 5,980,687 in view of Taniguchi et al., US 5,266,119 as applied to claims 1-2 and 9-10 above, and further in view of Kaminishizono et al., US 5,647,912 or Nishimoto et al., US 7,147,749 or Tomoyoshi et al., US 2004/0035364.

Koshimizu and Taniguchi et al. are applied as above but do not expressly disclose wherein the upper electrode is supported from underneath the lower electrode; and wherein the electrode supporting member includes an exhaust ring for uniformly exhausting the vacuum chamber and a cylindrical member for protecting an inner wall of the vacuum chamber. Kaminishizono et al. discloses an apparatus comprising a lower electrode and an upper electrode, wherein the upper electrode is supported from

10/802,811

Art Unit: 1792

underneath the lower electrode, the electrode supporting member includes an exhaust ring 7 for uniformly exhausting the vacuum chamber and a cylindrical member 11 for protecting an inner wall of the vacuum chamber (see, for example, figs. 4-6 and their descriptions). Additionally, Nishimoto et al. discloses an apparatus comprising a lower electrode 30 and an upper electrode 22, wherein the upper electrode is supported from underneath the lower electrode, the electrode supporting member includes an exhaust ring 64 for uniformly exhausting the vacuum chamber and a cylindrical member 26 for protecting an inner wall of the vacuum chamber (see, for example, fig. 1 and its description). Additionally, Tomoyoshi et al. discloses an apparatus comprising a lower electrode 2/12 and an upper electrode 3/13, wherein the upper electrode is supported from underneath the lower electrode (by structures 1/11 and 9/19), the electrode supporting member includes an exhaust ring 8/18 for uniformly exhausting the vacuum chamber and a cylindrical member 9/19-20 for protecting an inner wall of the vacuum chamber (see, for example, figs. 1 and 6, and their descriptions). In view of these disclosures, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Koshimizu modified by Taniguchi et al. so as to have the claimed electrode support member in order to, for example, reduce contamination of the chamber walls, provide suitable support for the electrode, and uniformly exhaust gasses from the chamber.

Concerning claims 6-7 and 14-15, note that the apparatus of Koshimizu in view of Taniguichi et al. and Kaminishizono et al. or Nishimoto et al. or Tomoyoshi et al., further comprises a substrate supporting member for supporting the substrate to be

Art Unit: 1792

processed above the lower electrode, wherein the substrate supporting member is vertically movable by the driving mechanism to pass through the lower electrode. With respect to claims 7 and 15, note that the distance between the first electrode and the second electrode in the apparatus of Koshimizu modified by Taniguchi et al. and further modified by Kaminishizono et al. or Nishimoto et al. is varied while constantly maintaining a volume of the vacuum chamber maintained in vacuum.

### Response to Arguments

Applicant's arguments filed 09/13/07 have been fully considered but they are not persuasive. Applicant argues that Taniguichi does not disclose the structure supporting member installed in the vacuum chamber. However, the examiner respectfully submits that the structure supporting member 7 in Taniguichi is largely contained within the vacuum chamber defined by the chamber walls. Moreover, note that item 8c is also installed within the chamber (see fig. 2).

Moreover, with respect to the Tomoyoshi et al. reference, applicant argues that both the structure supporting member and electrode supporting member are installed in the vacuum chamber. However, the reference numbers cited by applicant do not match the reference numbers in the Tomoyoshi et al. reference. Furthermore, the examiner respectfully submits that both the structure and electrode supporting members are contained within the walls of the processing chamber.

Concerning the Koshimizu reference and the structure and electrode supporting members being installed in the vacuum chamber, one cannot show nonobviousness by

attacking references individually where the rejections are based on combinations of references. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); *In re Merck* & Co., 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

#### Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Luz L. Alejandro whose telephone number is 571-272-1430. The examiner can normally be reached on Monday to Thursday from 7:30 to 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone

10/802,811 Art Unit: 1792

number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Primary Examiner

Art Unit 1792

November 20, 2007